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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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|-------------------------------------|---|----------------------|-----------------|
| Application of: | § | Attorney Docket No.: | 24061.514 |
| William Hong et al. | § | | TSMC2003-0299 |
| | § | | |
| Serial No.: 10/714,985 | § | Customer No. | 42717 |
| | § | | |
| Filed: November 17, 2003 | § | Group Art Unit: | 2813 |
| | § | | |
| For: Copper CMP Defect Reduction By | § | Examiner: | Thanh T. Nguyen |
| Extra Slurry Polish | § | | |
| | § | Conf. No.: | 2268 |

TRANSMITTAL

Mail Stop: AMENDMENT
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified patent application.

1. Amendment in Response to Office Action dated August 24, 2004;
2. Revocation/New Power of Attorney by Assignee of Entire Interest Including Certification for Taking Action by Assignee Under 37 CFR 3.73(b);
3. Check in the amount of \$72.00;
4. This transmittal (in duplicate); and
5. Return Receipt Postcard

The Director is authorized to charge any deficiency fees or credit any overpayments to Deposit Account No. 08-1394 of Haynes and Boone, LLP.

Respectfully submitted,

David M. O'Dell
Reg. No. 42,044

Date: 11-5-04

HAYNES AND BOONE, LLP
901 Main Street, Suite 3100
Dallas, Texas 75202-3789
Telephone: 972-739-8635
Facsimile: 214-200-0853

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner For Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on the date indicated below:

Bonnie Boyle

11-8-04
Date